## **Supplementary information**

## $\Phi\mbox{-scans}$ of samples not presented in the manuscript

Fig S1 shows  $\phi$ -scans that follow the discussion in relation to Fig 8 in the main manuscript, proving the proposed epitaxial relationships.



Figure S1  $\phi$ -scans of the (122)- and (10.10)-reflections of samples deposited on Al<sub>2</sub>O<sub>3</sub> r- (top) and c- (bottom), respectively. The samples are deposited using 666-cycles of 2:1 pulsing ratio of Nb:Li, and annealed at 650°C for 15min.

## Williamson-Hall analysis

Fig S2 shows the Williamson-Hall analysis conducted from the (012), (024), (036) and (048) reflections of LaAlO<sub>3</sub> and r-Al<sub>2</sub>O<sub>3</sub>. The corresponding particle sizes are XX and YY, respectively.



Figure S2 Williamson-Hall-plots of samples deposited on  $r-Al_2O_3$  (top) and LaAlO<sub>3</sub> (bottom), the data points are fitted to a straight line and the particle sizes corresponds to XX and YY. The samples are deposited using 666-cycles of 2:1 pulsing ratio of Nb:Li, and annealed at 650°C for 15min.

## X-ray reflectivity analysis

The figures below show the fitted data (red lines) and experimental values (blue dots) for samples with varying composition, corresponding to the reported values in fig 3 in the paper. The data is fitted to a model consisting of a silicon substrate, the film and a surface layer of  $Li_2CO_3$ . The samples deposited using 50 % and 26.7 % lithium pulses are not shown, as these samples could not be fitted due to high roughness or non-uniformity.

Pulsed ratio: 0 % Li-pulses, Thickness 921Å, Density 4.68 g/cm<sup>3</sup>, Roughness 11Å



Pulsed ratio: 10 % Li-pulses, Thickness 808Å, Density 4.17 g/cm<sup>3</sup>, Roughness 16Å, Top layer, 7.7Å



Pulsed ratio: 16.67 % Li-pulses, Thickness 878Å, Density 4.12 g/cm<sup>3</sup>, Roughness 7Å, Top layer, 15Å



Pulsed ratio: 20 % Li-pulses, Thickness 800Å, Density 4.08 g/cm<sup>3</sup>, Roughness 7.8Å, Top layer, 6Å



Pulsed ratio: 25 % Li-pulses, Thickness 866Å, Density 3.92 g/cm<sup>3</sup>, Roughness 11Å, Top layer, 30Å



Pulsed ratio: 33 % Li-pulses, Thickness 1202Å, Density 3.92 g/cm<sup>3</sup>, Roughness 19Å, Top layer, 33Å

